


Density functional theory study explaining the underperformance of copper oxides as photovoltaic absorbers

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Most photovoltaic absorbers are identified using the standard Shockley-Queisser selection principle which relies on optimal band-gap values. However, this criterion has been shown to be insufficient, as many materials with appropriate values still perform badly. Here, we have employed calculations based on the density functional theory to assess three copper oxides as potential photovoltaic materials: Cu_2O , Cu_4O_3 , and CuO . Despite their promising theoretical solar power conversion efficiency of over 20%, experimental values are found to be far lower. Theoretical evaluation of the electronic and optical properties reveals that certain transitions within the band structures are dipole forbidden, whereas the fundamental band gaps of Cu_4O_3 and CuO are of indirect nature. These findings correlate to the weak and shifted absorption properties found experimentally, which underpin the inefficient light capture by copper oxides. Based on these results and an applied extended selection metric, we can explain why copper oxides are unable to reach the efficiencies previously proposed theoretically and why we need to revise their maximum conversion values.

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I. INTRODUCTION

Copper is found as three different binary oxides: Cu_2O (cuprous oxide, also known as the mineral cuprite), CuO (cupric oxide or tenorite), and Cu_4O_3 (paramelaconite). Throughout history, copper oxides have been studied thoroughly, including both theoretical and experimental works, especially because their unique electronic and optical properties allow their potential applicability as transparent conducting oxides (TCOs) [1]. They are *p*-type semiconducting materials with band-gap values that make them suitable for photovoltaic (PV) applications [2]. In addition, copper oxides are abundant, nontoxic, and have low extraction costs [3].

Cu_2O is a well examined binary oxide of copper, especially for harvesting solar energy. Schottky junctions, homojunctions, and heterojunctions up to nanocomposite structures based on Cu_2O have all been studied extensively during the last two decades. However, the largest reported solar power conversion efficiency (PCE) has not exceeded 1%, and solar cells based on CuO and especially Cu_4O_3 have not achieved noticeable photovoltaic performances yet either. Solar cells based on CuO thin-film heterojunctions with amorphous silica have reached only 3% PCE [4], despite their almost ideal band-gap value which lies in the visible part of the electromagnetic spectrum [5]. So far, only Cu_2O has reached reasonable efficiencies of 5–6%, being part of multilayer solar cell devices [6].

The main reason that copper oxides are still attracting the attention of the scientific community is owing to the theoretical PCE of Cu_2O and CuO , which is estimated using the Shockley and Queisser (SQ) [7] predictor to be 20% and 30%, respectively [8]. Although, to the best of our knowledge,

data for the PCE of Cu_4O_3 do not exist, some authors have suggested that it could be a better absorbing material than the previously characterized copper materials [9]. Following those promising arguments, the inevitable question arises why copper oxides still fail to display good photovoltaic absorbing efficiencies.

PV efficiencies result from a complex interplay of structural, thermodynamic, magnetic, electronic, and optical characteristics. Modeling of those values computationally presents a challenge due to the large number of theories, equations, and approximations that one needs to take into account to obtain the whole picture.

Traditional first-principle methods employed for the theoretical study of copper oxides range from basic density functional theory (DFT) within the local-density approximation (LDA) [10], via parametrized approaches (Hubbard's + *U* approach [11]), to more sophisticated hybrid functionals (HSE06 [12], B3LYP [13], PBE0 [14]) and studies using Green's functions and the screened Coulomb interaction [15,16] (so-called *GW*: G_0W_0 (LDA) [17], GW^{RPA} [18], $scGW^{RPA}$ [18], $GW^{LF} + V_d$ (GGA+*U*) [19]). Basic DFT (using LDA and GGA) has failed to predict the electronic and magnetic structures of all three copper oxides, giving rise to metallic and non-magnetic CuO and Cu_4O_3 , and a very low band gap for Cu_2O (0.5 eV [10]). The main modeling issue with those CuO and Cu_4O_3 calculations lies within the strong hybridization between copper *d* and oxygen *p* orbitals. Supplementing DFT by an on-site Coulomb correction (DFT+*U*) allows one to tune the band gap of CuO and Cu_4O_3 , although the band gap of Cu_2O remains severely underestimated. DFT+*U* was created in order to describe the ordered ground state of correlated Mott/charge-transfer insulators such as CuO and Cu_4O_3 [19]. However, Cu_2O is a band insulator, and does not fall into this category [20]. Hybrid functionals give excellent structural results, but yield

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overestimated band gaps of strongly correlated materials like CuO and Cu₄O₃ [12], whereas recent work of Rödl *et al.* [21] showed that electronic structure calculations of CuO are extremely sensitive to details of employed *GW* iteration schemes. Wang *et al.* [19] performed *GW* calculations including DFT-derived local field effects (*GW*^{LF}) with an additional on-site potential ($+V_d$) to lower the *d*-orbital energies that are systematically located too high. This approach reproduced the band-gap values of Cu₂O and CuO rather well, while leaving the value for Cu₄O₃ too low. Although the *GW* method seems accurate enough, it is computationally rather expensive, and it still needs to be evaluated whether it can predict properties of unknown compounds, e.g., doped materials, nanostructures, or junctions.

As we are aware of the detailed work that has already been carried out on all three copper oxides, and in particular CuO and Cu₂O, the aim of this paper is not to duplicate existing data, but rather to define an affordable approach and address the missing parts that could help explain some of the major questions still open in this area. In the present work we have performed first-principle calculations within a set of unique approximations, but relying on the minimal number of additional parameters, for the description of all three oxides of copper. Furthermore, we have assessed their mechanical, electronic, magnetic, and optical properties and linked them to theoretical values of photovoltaic efficiencies. In addition, it was our aim to extend the standard SQ limit and obtain insight into the reason why copper oxides fail to achieve high solar-absorbing photovoltaic efficiencies, despite their promising energy band-gap values.

II. COMPUTATIONAL METHODS

We have performed density functional theory (DFT) calculations of all three copper oxides using the Vienna Ab Initio Simulation Package (VASP) code [24,25] with a plane-wave basis set and PAW potentials [26,27]. The Perdew-Burke-Ernzerhof (PBE) general gradient approximation (GGA) [28] for the exchange-correlation (XC) functional was used for both DFT and DFT+*U* [29–32], while the hybrid-DFT XC functional was used with an additional 25% of the exact Hartree-Fock (HF) exchange (HSE06) [33–35]. The total energy was required to converge to within 10^{-5} eV, and the interatomic forces were minimized to less than 0.01 eV/Å for structural relaxations.

For the Brillouin-zone sampling, a Γ -centered Monkhorst-Pack *k* mesh was used [36]. Long-distance dispersion corrections were included using the D3 approach of Grimme *et al.* [37] and spin polarization was taken into account. Convergence of the size of the plane-wave basis and the number of *k* points employed was tested independently for Cu₂O, CuO, and Cu₄O₃. A cutoff energy of 500 eV together with $7 \times 7 \times 7$, $5 \times 5 \times 5$, and $5 \times 5 \times 3$ meshes, respectively, was sufficient to reach convergence. The total energy was required to converge to within 10^{-5} eV, and the interatomic forces were minimized to less than 0.01 eV/Å for structural relaxations. Band structure and density of states (DOS) calculations were performed along high-symmetry directions obtained from the Bilbao Crystallographic Server [38–40]. The band structures were plotted using the Wannier90 code

[41]. Crystal structure drawings were produced with VESTA [42]. Due to the increasing computational cost of our proposed approach, and in order to compare structural and mechanical properties, a simplified arrangement of CuO spins was adopted, rather than the fully extended model proposed by Forsyth *et al.* [43]. Values for the effective Hubbard parameter U_{eff} were applied on the localized 3*d* electrons of Cu, and systematically varied in intervals of 1 eV from 0 eV up to 9 eV. For each material, the atomic positions and lattice parameters were fully relaxed until the required convergence criterion was satisfied. Calculated values were compared with experimental lattice parameters, magnetic moments, and band-gap values. On this basis, we determined a common U_{eff} value of 8 eV to give the closest representation of the properties of interest in all three copper oxides. Using the DFT+*U* generated wave functions and relaxed geometries as starting points, additional hybrid DFT calculations were performed in two different ways. In the first approach, we allowed the geometry to fully relax, while the second approach included one static self-consistent calculation, which showed no significant differences in band structures, magnetic configurations, or lattice parameters. Frequency-dependent dielectric calculations were performed within the independent particle approximation, and electronic allowed or forbidden band gaps were determined from the dipole matrix element square at the Γ point, $|M|^2$. $|M|$ contains dipole transition matrix elements between valence and conduction states. If $|M|^2 < 10^{-3}$ eV²/Å², the transition was considered to be dipole forbidden, otherwise it was viewed as dipole allowed [9]. Local-field effects have been neglected. The number of empty conduction states in the calculation was checked for convergence until the same values were obtained as resulted from density functional perturbation theory embedded in VASP. We noted that the dipole matrix elements do not depend on the employed XC functional, i.e., they retain the nature of transitions. To assess the PV absorbing potential of copper oxides we followed the selection metric of spectroscopic limited maximum efficiency (SLME) proposed by Yu and Zunger [44]. This concept allowed us to evaluate the PV conversion efficiency of copper oxides relying on two calculated values: absorption spectrum and band gap. SLME reproduces the SQ metric in the simple case of direct allowed band-gap materials. The elastic tensor was determined by performing finite lattice distortions (which allow the calculation of the Hessian matrix) and elastic constants were derived from the strain-stress relationship [45]. Spin-orbit coupling and excitonic effects were not included in this work.

III. RESULTS AND DISCUSSION

Copper (I) oxide is a *p*-type semiconductor with a high-symmetry cubic structure. It contains six atoms in the unit cell, four Cu atoms which form a face-centred sublattice, and two O atoms which constitute a body-centred sublattice (see Table I for a summary of crystallographic and geometric properties), as shown in Fig. 1. *Copper (II) oxide* crystallizes in a lower symmetry monoclinic structure. The unit cell consists of eight atoms, four Cu and four O atoms, where each copper atom is coordinated by four oxygen atoms in an approximately square planar configuration. *Paramelaconite* (Cu₄O₃), a rare intermediate between CuO and Cu₂O, crystallizes in a

TABLE I. Experimental values of structural parameters for Cu_2O , Cu_4O_3 , and CuO taken from Refs. [22], [23], and [12], respectively.

	Cu_2O	Cu_4O_3	CuO (eV)
Lattice constant (\AA)	$a = 4.269$	$a = 5.837$ $c = 9.932$	$a = 4.683$ $b = 3.422$ $c = 5.128$
Space group	$Pn\bar{3}m$ (224)	$I4_1/amd$ (141)	$C2/c$ (15)
Crystal structure	cubic	tetragonal	monoclinic
Cu-O (\AA)	1.849	1.870	1.960
O-O (\AA)	3.698	2.560	2.620
Cu-Cu (\AA)	3.019	2.920	2.900

tetragonal structure. The main difference between CuO and Cu_4O_3 is that the addition of oxygen to certain atomic sites converts a rod of Cu^+ into a rod of Cu^{2+} atoms. This causes a change in the topology of the magnetic lattice, making Cu_4O_3 antiferromagnetic (AFM) below 40 K with a magnetic moment localized on the Cu^{2+} atoms with a value of $0.46\text{--}0.66\mu_B$ [12]. Thus far, Cu_4O_3 has been synthesized as thin films, while it has still not been possible to completely eliminate the bulk form from mixture phases [46].

A. Structural and mechanical properties

We first modelled the copper-oxide structures by considering the bulk unit cell. Overall, the calculated lattice parameters reproduce experimental data very well, as shown at the top of Table II.

Elastic constants and elastic moduli are among the most fundamental parameters that provide information on the mechanical properties and behavior of materials. Depending on the lattice symmetry and point group, the number of inequivalent elastic coefficients for each oxide of copper differs: 3 for Cu_2O , 13 for CuO , and 6 for Cu_4O_3 . We have calculated the elastic constants and different elastic properties, e.g., the bulk modulus (B), shear modulus (G), effective Young's modulus (E), and Poisson's ratio (ν), and summarized them in Tables II–V. To confirm values obtained from elastic constant calculations we have deduced the bulk modulus from a Birch-Murnaghan equation of state (EOS) [49]. We note how calculated values fall within the experimental range of available

data, confirming the high accuracy of the proposed modeling approach. Furthermore, compared to previous theoretical data, the elastic constants do not show negative values, indicating the stability and rigidity of bulk copper oxides.

We have also explored the stiffness of copper oxides through calculations of the microhardness parameter (H) [47], which denotes the resistance of a physical object against compression of the contacting parts. Based on this characterization, only copper (II) oxide can be regarded as a hard material, with Cu_4O_3 falling closely behind (hard materials reach values of $H > 10$ [51]). In addition, the equivalent Zener anisotropy factor (A_z^{eq}) was examined in order to explore the anisotropy characteristics of the crystal. A factor that is close to 1 means that the material is fully isotropic, otherwise it is elastically anisotropic. Interestingly, the value for Cu_2O is higher than the one for CuO , indicating greater isotropy for the monoclinic structure (perhaps due to instability), with Cu_4O_3 being highly anisotropic.

B. Electronic properties

In contrast to its mechanical properties, the electronic properties of Cu_2O are not correctly described with GGA, giving rise to a band-gap value of only 0.5 eV. An additional potential ($+U_{\text{eff}}$) to GGA increases the value to 0.95 eV, which is still less than half of the experimental value (2.10–2.38 eV [40]). The cause of this discrepancy has been explained and reported extensively [11,52,53]. A major improvement was obtained using hybrid functionals, which led to the calculated values listed in Table VI (band structure shown in Fig. 2). Broadly speaking, the electronic structure calculations of bulk Cu_2O show the typical features that have already been described [4,9].

Calculations of the electronic dipole transition matrix provide insight into the nature of certain band transitions and rationalize the link to absorption properties. For Cu_2O , the first transition between the top of the valence band and the bottom of the conduction band is electric dipole forbidden, agreeing with previous observations [54–56]. Nevertheless, this transition is electric quadrupole allowed (and possibly magnetic dipole allowed, which has only been speculated upon so far) so that, linking it to the absorption spectra and dielectric function, it will give rise to a small, almost negligible absorption onset. The first allowed transitions are from the two top valence bands to the second conduction band with calculated energies of 2.478 and 2.485 eV, respectively. The nature and values of the transitions correspond very well with experimental data, as shown in Table VI. Furthermore, it should also be noted that no spin-orbit interaction was included in the calculations, which is known to affect the top of the valence band by an additional splitting of 0.15 eV [9].

CuO is a strongly correlated system and standard DFT fails to predict its semiconducting ground state, obtaining a nonmagnetic (zero local magnetic moment) and metallic ground state instead [57–59]. However, by adding and tuning the $+U_{\text{eff}}$ value, the electronic and magnetic structure of cupric oxide is simulated accurately [32,60]. Surprisingly, adding a portion of the exact HF exchange does not seem to systematically improve the electronic structure calculations for CuO (band structure has been shown in Fig. 2). Heinemann

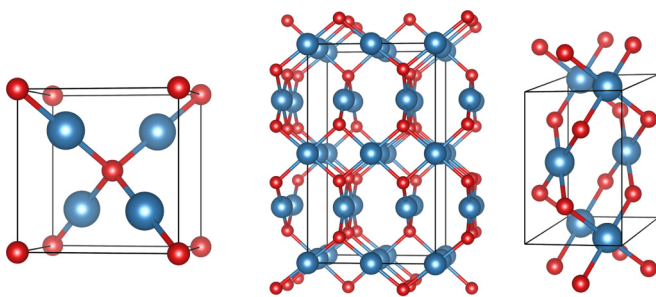


FIG. 1. Crystal structure of copper oxide compounds: (left) Cu_2O (left), Cu_4O_3 (middle), and CuO (right). Blue coloured balls represent copper atoms, while red coloured balls represent oxygen atoms.

TABLE II. Calculated values of structural and elastic properties for Cu₂O, Cu₄O₃, and CuO using DFT, DFT+*U* (*U* = 8 eV), and HSE06. The shear and first bulk modulus were calculated using the Voigt-Reuss-Hill approximation [47], while an additional bulk modulus was calculated using the Birch-Murnaghan equation of state.

		Cu ₂ O	Cu ₄ O ₃	CuO
Lattice parameter (Å)	DFT	4.271	5.863, 9.939	4.716, 3.439, 5.104
	DFT+ <i>U</i>	4.231	5.742, 9.970	4.648, 3.439, 5.031
	HSE06, relaxed	4.253	5.773, 9.928	4.670, 3.455, 5.055
	HSE06, single point	4.231	5.742, 9.970	4.648, 3.439, 5.031
	Experimental	4.269 [22]	5.837, 9.932 [12]	4.683, 3.422, 5.128 [23]
Bulk modulus, Hill (GPa)	DFT	114.07	119.26	101.32
	DFT+ <i>U</i>	102.60	118.89	99.16
	DFT	108.66	127.35	144.25
Bulk modulus, EOS (GPa)	DFT+ <i>U</i>	94.40	110.10	95.58
	Experimental	9.1–11.9 [48]		
	DFT	7.06	42.96	54.50
Shear modulus (GPa)	DFT+ <i>U</i>	5.06	57.69	78.92
	Experimental	9.1–11.8 [48]		
	DFT	20.76	115.08	138.65
Young modulus (GPa)	DFT+ <i>U</i>	14.92	148.99	187.12
	Experimental	25.3–32.3 [48]		
	DFT	0.142	4.607	8.286
Microhardness parameter (GPa)	DFT+ <i>U</i>	0.081	8.033	16.547
	Experimental			
	DFT	0.469	0.339	0.271
Isotropic Poisson ratio	DFT+ <i>U</i>	0.475	0.291	0.185
	Experimental	0.360–0.391 [48]		
	DFT	1.933	4.661	1.217
Equivalent Zener anisotropy factor	DFT+ <i>U</i>	1.469	7.262	1.041
	Experimental			

et al. [12] performed HSE06 calculations on top of LDA + *U* and obtained a value of 2.74 eV with an indirect nature of the band gap and AFM ordering. Our calculations employing hybrid functionals on top of GGA + *U* gave a value of 2.102 eV with the same indirect nature of the fundamental transition and a magnetic moment placed entirely on copper atoms with an individual value of 0.70 μ_B (agreeing well with the experimental value of 0.68 μ_B [34]). In addition, we calculated and compared the total energies of all the possible AFM ground-state configurations of CuO employing hybrid functionals. Surprisingly, band-gap values range from 2.102 to 2.718 eV, keeping the nature of the transition intact (Fig. 3). This indicates that not all AFM spin configurations are equally favorable and that CuO is sensitive to the initial calculation parameters.

However, while comparing those results, one must keep in mind that the experimental results are still neither conclusive

TABLE III. Calculated values of elastic constants for Cu₂O using DFT, DFT+*U* (*U* = 8 eV).

	<i>c</i> ₁₁	<i>c</i> ₁₂	<i>c</i> ₄₄
Expt. [50]	116–126	105–108	11–13
DFT	121.46	110.39	2.86
DFT+ <i>U</i>	106.23	100.79	3.99

about the value of the band gap nor its nature. Significant discrepancies in values (ranging from 1.0 eV to almost 2.0 eV) could be attributed to the low symmetry and anisotropy of the crystal [61], strong temperature dependence of the band gap (due to strong electron-phonon coupling) [62], large temperature dependence of the absorption edge and Urbach tail (connected to the previous point) [63], and to the inadequacy of the simple Tauc expression to fit the experimental absorbance data [61].

Dipole transition matrix element calculations could clarify the picture for CuO. These suggest that the nature of the transport gap is not only indirect, but also forbidden on the basis of the electric dipole. Furthermore, the next three transitions between the valence and conduction band (ordered by the lowest possible energy) indicate dipole forbidden character. The first allowed transition occurs at an energy difference bigger than 4 eV and only in certain directions within the

TABLE IV. Calculated values of elastic constants for Cu₄O₃ using DFT, DFT+*U* (*U* = 8 eV). No experimental work is, to the best of our knowledge, available to compare with.

	<i>c</i> ₁₁	<i>c</i> ₁₂	<i>c</i> ₄₄	<i>c</i> ₁₃	<i>c</i> ₃₃	<i>c</i> ₆₆
DFT	156.96	64.14	9.96	113.52	227.51	7.78
DFT+ <i>U</i>	186.76	44.01	9.82	101.38	250.07	3.92

TABLE V. Calculated values of elastic constants for CuO using DFT, DFT+ U ($U = 8$ eV).

	c_{11}	c_{12}	c_{44}	c_{13}	c_{33}	c_{66}	
Ref. [50]	196.41	122.63	20.28	114.64	293.70	56.44	
DFT	243.28	132.03	45.70	151.88	277.56	63.50	
DFT+ U	258.19	139.52	56.99	118.93	312.80	106.67	
	c_{22}	c_{55}	c_{15}	c_{23}	c_{25}	c_{35}	c_{46}
Ref. [50]	125.01	30.07	-26.99	96.89	-27.85	-48.94	-1.15
DFT	96.26	13.59	0.00	87.71	0.00	0.00	0.00
DFT+ U	109.83	56.99	0.00	57.26	0.00	0.00	0.00

crystal. This information could serve as a starting point for new and accurate experimental work, but also for theoretical work incorporating spin-orbit coupling effects, which could affect those values and induce possible band splitting.

Unlike the case of CuO, basic DFT reproduces a small band-gap value for Cu₄O₃ and results in fully nonmagnetic behavior. By employing GGA + U methodology the value of the gap increases to 1.558 eV, together with a recovery of the AFM ordering and magnetic moment of $0.71\mu_B$. Hybrid functional calculations show a dipole forbidden indirect band transition between the valence and conduction band, with a band-gap value of 2.370 eV and magnetic moment of $0.68\mu_B$, as is shown in Fig. 2 (agreeing well with the experimental value of $0.46-0.66\mu_B$ [12]). However, as Heinemann *et al.* [12] pointed out, experimental values for Cu₄O₃ are still inconclusive regarding both the value and the nature of the band transition.

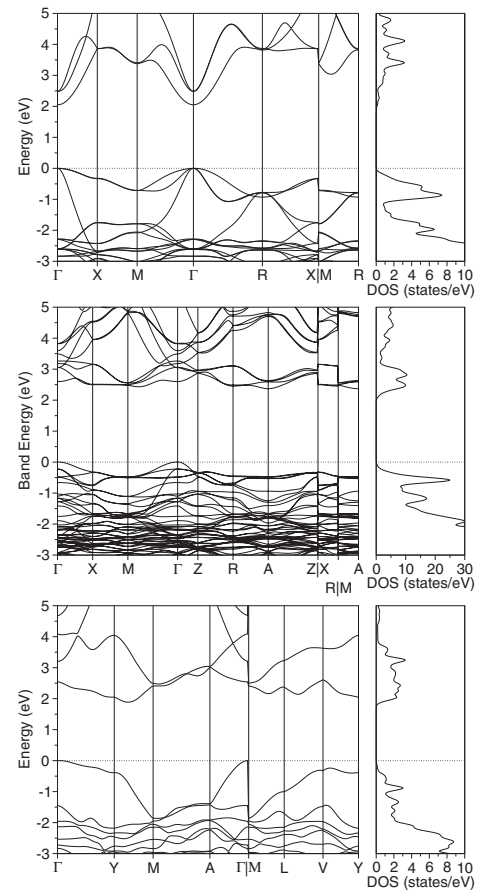
C. Optical properties

The calculated real and imaginary parts of the dielectric functions of Cu₂O, CuO, and Cu₄O₃, together with their corresponding absorption coefficients obtained using HSE06, are shown in Figs. 4 and 5. In the calculated absorption spectra of Cu₂O, the two aforementioned allowed transitions can be observed at around 500 nm \approx 2.5 eV. Hybrid functionals tend to give roughly the right positions of the peaks but slightly underestimate their intensity. The imaginary part of the dielectric function shows similar results for the positions of the transition energies.

Within the experimental data of the imaginary part of the dielectric function of CuO, Meyer *et al.* [9] were able to identify multiple positions of possible interband transitions. Our dipole matrix calculations explain why it is difficult to

TABLE VI. Calculated band-gap energies of Cu₂O, Cu₄O₃, and CuO compared to experimental values. Also, the estimated nature of the transition together with the type of the band gap are enlisted.

Compound	Type of transition	Nature of transition	DFT (eV)	DFT+ U (eV)	HSE06 (eV)	Experimental value (eV)
Cu ₂ O	Direct	Dipole forbidden	0.535	0.945	2.052	2.10–2.38 [64]
	Indirect				2.370	
Cu ₄ O ₃	Direct	Dipole forbidden	0.333	1.558	2.620	1.34–1.50 [12], 1.75 [65]
	Indirect			1.485	2.102	
CuO	Direct	Dipole forbidden	0.607	1.916	2.578	1.0–1.9 [9,23,66]

FIG. 2. Band-structure diagrams of Cu₂O, Cu₄O₃, and CuO. The valence-band maximum has been set to zero.

identify those transitions within the dielectric function or by looking at the shape of the absorption coefficient curve. Unlike Cu₂O, CuO seems to have a more complex band structure and transition occurrence between certain bands, where a dipole forbidden nature could be responsible for hardly visible interband transitions. Looking closer at the absorption coefficient curve between 2 and 3 eV gives an idea when the absorption of photons starts to take place, but the extremely low intensity and smeared peaks are not conclusive about a precise onset of absorption.

Calculations of optical properties for Cu₄O₃ suggest low absorption until the energy of the incident photon reaches 3.250 eV (around 380 nm). One additional stronger peak can be observed at around 3.600 eV (around 345 nm) which

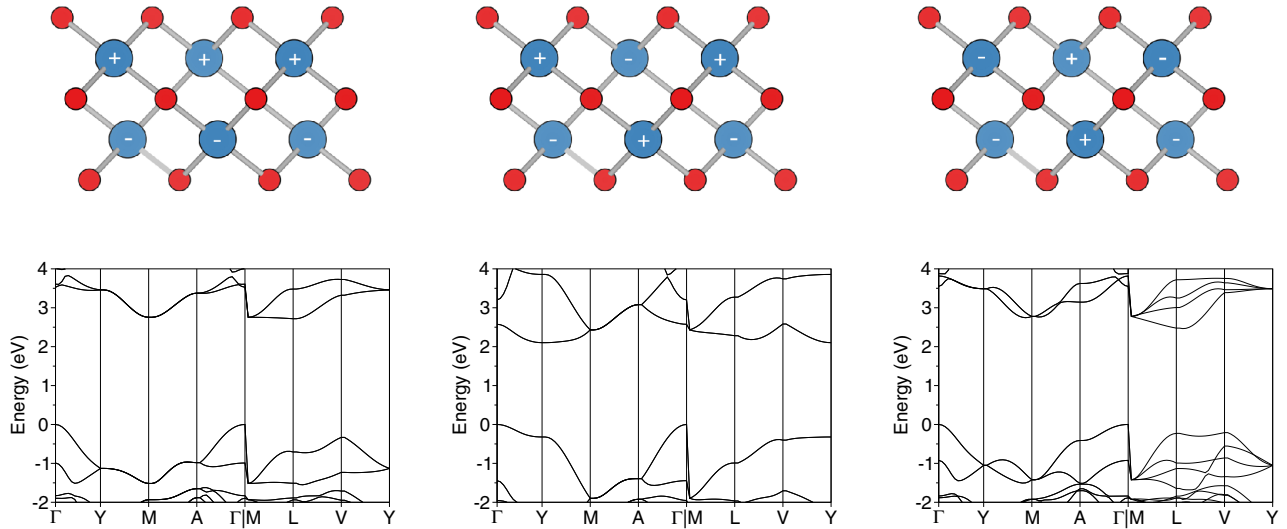


FIG. 3. Calculated band structures using HSE06 functional for CuO in three different ground-state antiferromagnetic configurations.

could be assigned to a possible interband transition, but to the best of our knowledge, experimental data are lacking to confirm this suggestion. Other transitions cannot be observed as the absorption curve shows hardly any peaks in the relevant visible spectrum.

D. Photovoltaic absorber efficiency

By combining the nature of the elementary transitions between valence and conduction bands with their dipole allowance and accompanying absorption spectra, we have extended the classic SQ limit for copper oxides to the SLME metric. This approach classifies copper oxides into different groups of optical materials, according to the order of dipole allowed and forbidden transitions (more details on the division scheme can be found in Yu and Zunger [44]). As mentioned before, the lowest energy transition of Cu₂O is direct dipole forbidden, followed by a direct allowed transition. For Cu₄O₃ and CuO the first transitions are indirect dipole forbidden as

shown in Fig. 6. In the case of Cu₄O₃, the following transition is an indirect, but dipole allowed, transition, while for CuO we note only forbidden transitions within the visible part of the electromagnetic spectrum. SLME calculations give absorbing efficiencies based upon those considerations.

The calculated dependence of SLME on the film thickness for copper oxides is shown in Fig. 7. Choosing a reasonable reference thin-film thickness of 0.5 μm we obtain 0.54% and 1.40% efficiency for Cu₂O and Cu₄O₃, respectively. This corresponds well with experimentally observed PCE values, which take values of 1–2% for Cu₂O and CuO [4,9,68]. For Cu₄O₃ no experimental PCE values have been obtained, to the best of our knowledge. It is also worth mentioning that increasing the thickness leads to a plateau in efficiency. In other words, Cu₂O single-crystal compounds cannot exceed conversion efficiencies of 1% without further modification. For Cu₄O₃, this threshold is slightly higher, reaching 2–3%. As noted, CuO does not appear in the analysis due to negligible efficiency values, attributed to low absorption onsets

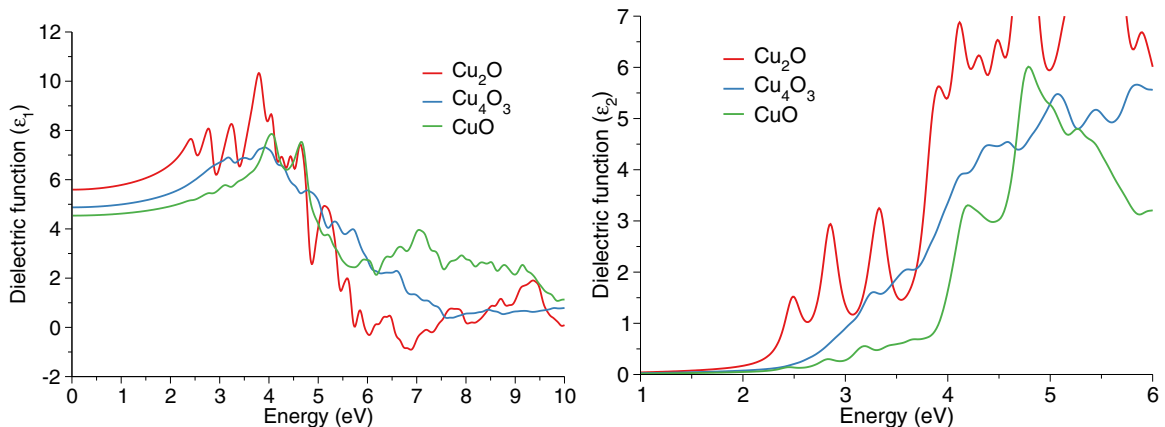


FIG. 4. Calculated real part of the dielectric function (ϵ_1 , left) and imaginary part of the dielectric function (ϵ_2 , right) for Cu₂O, Cu₄O₃, and CuO employing the HSE06 functional.

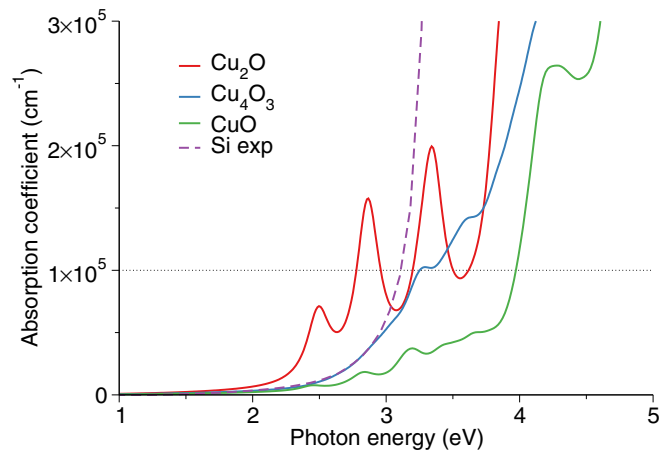


FIG. 5. Calculated absorption coefficient for Cu_2O , Cu_4O_3 , and CuO using the HSE06 functional averaged over Cartesian coordinates. For comparison, the silicon experimental value has been shown with the purple dashed line [67].

and a clear majority of electrically dipole forbidden transitions that govern weak interactions between the incoming sunlight and valence electrons. In addition, photons that get absorbed by CuO are not efficiently converted due to significant nonradiative recombination processes inside the material. This correlates well with experimentally observed charge recombination processes preventing large-scale application of CuO -based solar cells [69,70]. This is attributed to the large radiative fraction (order of 10^{-40}) which is used to calculate the reverse saturation current, imposing a significant influence on the open circuit voltage of the operating device. If we model CuO as a direct gap material, the maximum efficiency obtained does not exceed 2–3%. This implies that even if the nonradiative recombination processes are neglected, the absorption of CuO is very low and does not produce favorable output voltages.

These findings suggest that single-crystal copper oxides cannot be efficiently employed as solar-collecting materials.

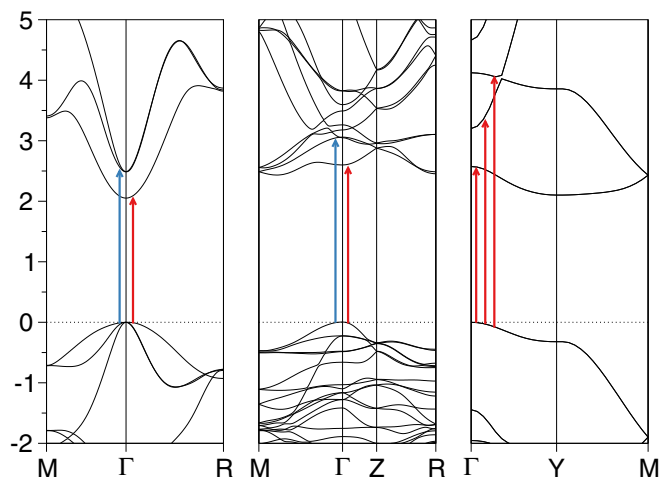


FIG. 6. Energy-band structure diagram of Cu_2O , Cu_4O_3 , and CuO (from left to right) showing dipole allowed (blue arrow) and dipole forbidden (red arrow) transitions between the valence and conduction band.

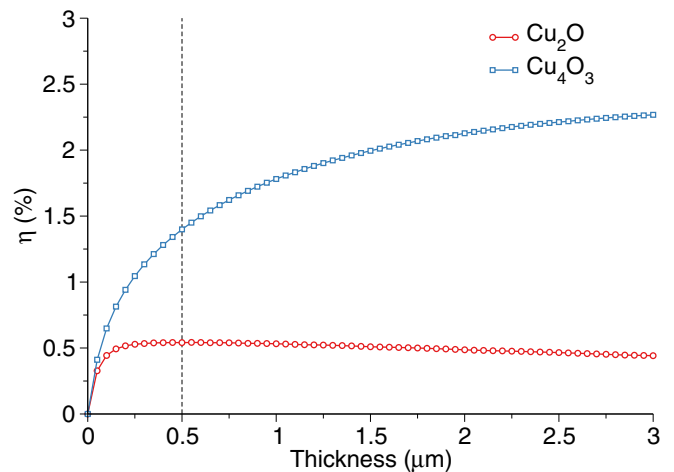


FIG. 7. Calculated spectroscopic limited maximum efficiency (SLME) plotted as a function of the film thickness.

However, modifying the material's inner properties could lead to notable improvements. I.e., introducing extrinsic dopants could allow one to tune the Fermi level and create defect states situated within the band gap. Photon-induced transitions from defect states can lead to enhanced photocurrent generation through subband-gap absorption. This has been already demonstrated by electrochemical doping in n -type Cu_2O with chlorine [71]. It improved the conductivity of Cu_2O and hence, the overall efficiency of an intrinsic p - n junction of Cu_2O . Also, defect states can cause carrier trapping or additional nonradiative recombination, depending on the position of the defect state relative to the valence or conduction band. First-principle calculations can explore unreported promising materials or provide insights into defect energetics without the need of previous synthesis.

Another possibility is the combination of copper oxides with other materials to create tandem cells. Improvement has been demonstrated, i.e., by creating heterojunction solar cells between AZO, Ga_2O_3 , and Cu_2O . This has led to an increase in efficiency to almost 5.5% [6]. If we compare this efficiency to the almost negligible conversion as a single cell, it offers suggestions for new designs. However, while forming junctions with copper oxides, the control of the interface properties is crucial in order to avoid mixture phases. Again, first-principle calculations can provide useful information which include Schottky barrier heights of interfaces, band offsets, or band positioning.

IV. CONCLUSION

We have modelled the photovoltaic efficiency of copper oxides using density functional theory. Our DFT+ U and HSE06 calculations have proven to be a computationally feasible and accurate approach to determine the electronic, magnetic, and optical properties. Cu_2O , Cu_4O_3 , and CuO are shown to be semiconductors with different types of fundamental band-gap transition. Moreover, we have reported dipole transition matrix calculations which allowed us to characterize certain transitions from the valence to the conduction band and to assign them to peaks in the dielectric function and

absorption spectrum. Finally, we have extended the usual SQ limit into the SLME metric, which has allowed us to explain why bulk single-crystal copper-oxides solar cells have low photovoltaic conversion efficiencies, as is seen experimentally. Future calculations could incorporate phonon-assisted interband transitions and absorption spectra into the SLME metric (or equivalent) in order to obtain even better descriptors and accurate prediction.

Information on the data underpinning the results presented here, including how to access them, can be found in the Cardiff University data catalog [72].

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